

## TECHNICAL PROGRAM

	MONDAY, DECEMBER 8th, 2014	PART NO.
08:00-08:20	<b>OPENING – WELCOME - INTRODUCTION</b> <b>Y. N. Zhou<sup>1</sup>, A. Hirose<sup>2</sup>, J. Janczak-Rusch<sup>3</sup>, L.P.H. Jeurgens<sup>3</sup></b> <sup>1</sup> University of Waterloo, Centre for Advanced Materials Joining, Canada <sup>2</sup> Osaka University, Division of Materials and Manufacturing Science, Japan <sup>3</sup> Empa, Swiss Federal Laboratories for Materials Science and Technology, Switzerland	<b>CHAIRS</b>
Session	<b>ORAL SESSION I (PLENARY)</b>	
Room	<b>SEEBLICK</b>	
Chair	<b>Y.N. Zhou, L.P.H. Jeurgens</b>	
08:20	<b>ASSEMBLY AND PACKAGING TECHNOLOGIES FOR POWER DEVICES AND MODULES</b> <b>Y. Kashiba</b> Manufacturing Engineering Center, Mitsubishi Electric Corporation, Japan	<b>KEYNOTE</b> <b>K1</b>
09:00	<b>HIGH TEMPERATURE VIABLE INTERCONNECTION REALIZED BY SINTERING Sn-M IMC NANOALLOYS AT LOW TEMPERATURE</b> <b>C. Wang, Y. Zhong, Z. Zheng</b> State Key Lab. of Advanced Welding & Joining, Harbin Institute of Technology, China	<b>KEYNOTE</b> <b>K2</b>
09:40	<b>SYNTHESIS AND CHARACTERIZATION OF NANOTHERMITE FOR MICRO-JOINING APPLICATIONS</b> <b>J. Z. Wen</b> Dept. of Mechanical & Mechatronics Engineering, University of Waterloo, Canada	<b>INVITED</b> <b>I4</b>
10:00-10:30	<b>COFFEE BREAK</b>	
Session	<b>ORAL SESSION II (PLENARY)</b>	
Room	<b>SEEBLICK</b>	
Chair	<b>A. Hirose, J. Janczak-Rusch</b>	
10:30	<b>SIZE EFFECTS ON THE THERMODYNAMIC PROPERTIES OF NANOALLOYS</b> <b>C. Ricolleau<sup>1</sup>, G. Prévot<sup>2</sup>, J. Nelayah<sup>1</sup>, G. Wang<sup>1</sup>, D. Alloyeau<sup>1</sup></b> <sup>1</sup> Laboratoire Matériaux et Phénomènes Quantiques, Université Paris 7 – CNRS, France <sup>2</sup> Institut des Nanosciences de Paris, Université Paris 6 – CNRS, France	<b>INVITED</b> <b>I2</b>
10:50	<b>MICROSTRUCTURAL EVOLUTION OF NANO-STRUCTURED Ag-Cu/AlN BRAZING FILLERS UPON HEATING</b> <b>M. Lewandowska<sup>1</sup>, M. Andrzejczuk<sup>1</sup>, G.Pigozzi<sup>2</sup>, L.P.H. Jeurgens<sup>2</sup>, J. Janczak-Rusch<sup>2</sup></b> <sup>1</sup> Warsaw University of Technology, Faculty of Materials Science and Engineering, Poland <sup>2</sup> Empa, Swiss Federal Laboratories for Materials Science and Technology, Switzerland.	<b>Invited</b> <b>I3</b>
11:10	<b>SILVER SINTER JOINING AND NEW THIN FILM BONDING FOR WBG DIE-ATTACH</b> <b>K. Suganuma, S. Nagao, T. Sugahara, C. Oh, H. Zhang, S. Koga, S. Park</b> Institute of Scientific and Industrial Research, Osaka University, Japan	<b>INVITED</b> <b>I5</b>
11:30	<b>COPPER NANOCOMPOSITE PASTE FOR HIGH RELIABLE INTERCONNECTION AND ITS JOINING CHARACTERISTICS</b> <b>K.-S. Kim, S.-B. Jung</b> School of Advanced Materials Science and Eng., Sungkyunkwan University, Republic of Korea	<b>R0</b>
11:50	<b>NANO BRAZING TECHNOLOGY IN INDUSTRIAL ENVIRONMENT</b> <b>M. Türpe</b> MAHLE Behr GmbH & Co. KG, Stuttgart, Germany	<b>R1</b>
12:10-13:30	<b>LUNCH</b>	

	MONDAY, DECEMBER 8th, 2014	PART NO
Session	<b>ORAL SESSION III (PLENARY)</b>	
Room	<b>SEEBLICK</b>	
Chair	<b>G. Zou, W. Tillmann</b>	
13:30	<b>BRIDGING THE GAP BETWEEN ATOMISTICS AND THERMODYNAMICS OF INTERFACES TO CONTROL WETTING AND PHASE FORMATION FOR METAL-CERAMIC JOINS</b> <u>W.D. Kaplan</u> <i>Israel Institut of Technology, Israel</i>	<b>KEYNOTE</b> <b>K3</b>
14:10	<b>STATE-OF-THE-ART LOCAL ELECTROCHEMICAL CHARACTERISATION OF MICRO- AND NANO-JOINTS</b> <u>T. Suter, P. Schmutz, J. Janczak-Rusch</u> <i>Empa, Swiss Federal Laboratories for Materials Science and Technology, Switzerland</i>	<b>R2</b>
14:30	<b>JOINING TECHNOLOGY THROUGH SINTERING OF SILVER NANOPARTICLES DERIVED FROM SILVER OXIDE PASTE</b> <u>T. Ogura, A. Hirose</u> <i>Division of Materials and Manufacturing Science, Graduate School of Engineering, Osaka University, Japan</i>	<b>R3</b>
14:50	<b>JOINING OF COPPER BY AG NANOPASTE: MICROSTRUCTURE AND STRENGTH BEHAVIOUR</b> <u>B. Wielage, S. Weis, H. Podlesak, S. Hausner</u> <i>Institute of Materials Science and Engineering, Germany</i>	<b>R4</b>
15:10	<b>SYNTHESIS AND LIGHT INDUCED NANOJOINING OF SILVER NANOWIRES</b> <u>Y. Tian, S.Ding, C. Wang</u> <i>State Key Laboratory of Advanced Welding and Joining, Harbin institute of technology, China</i>	<b>R5</b>
15:30-16:00	<b>COFFEE BREAK</b>	
Session	<b>ORAL SESSION IV (PLENARY)</b>	
Room	<b>SEEBLICK</b>	
Chair	<b>A. Hu, B. Wielage</b>	
16:00	<b>RELIABILITY OF LEAD-FREE SOLDER JOINTS IN MICROELECTRONICS</b> <u>E. Hodúlová, B. Šimeková, I. Kovaříková</u> <i>Slovak University of Technology in Bratislava, Faculty of Materials Science and Technology in Trnava Institute of Production Technologies, Slovak Republic</i>	<b>INVITED</b> <b>I6</b>
16:20	<b>WIREBONDER-MADE MICRO ELECTRO MECHANICAL SYSTEMS</b> <u>J. G. Korvink<sup>1</sup>, U. Wallrabe<sup>2</sup></u> <sup>1</sup> University of Freiburg, Dept. of Microsystems Eng., Laboratory for Simulation, Germany <sup>2</sup> University of Freiburg, Dept. of Microsystems Eng., Laboratory for Microactuator, Germany	<b>INVITED</b> <b>I7</b>
16:40	<b>EFFECT OF RAPID SOLIDIFICATION ON MICROSTRUCTURE AND PROPERTIES OF Sn-Ag-Cu LEAD-FREE SOLDER</b> <u>S. Lu, F. J. Wang, Z.X. Zheng</u> <i>Provincial Key Laboratory of Advanced Welding Technology, Jiangsu University of Science and Technology, China</i>	<b>R6</b>
17:00	<b>LEAD FREE BGAS SOLDERED WITH SnPb SOLDER</b> <u>G. Grossmann<sup>1</sup>, G. Nicoletti</u> <i>EMPA, Swiss Federal Laboratories for Materials Science and Technology, Switzerland</i>	<b>R7</b>
17:20	<b>EFFECT OF ISOTHERMAL AGING ON IMPACT STRENGTH OF Sn-Ag-Cu SOLDER BUMPS</b> <u>J. X. Wang<sup>1,2</sup>, H. Nishikawa<sup>2</sup></u> <sup>1</sup> Jiangsu Provincial Key Laboratory of Advanced Welding Technology, Jiangsu University of Science and Technology, China <sup>2</sup> Joining and Welding Research Institute, Osaka University, Japan	<b>R8</b>
17:40	<b>EFFECT OF THERMAL TREATMENT ON Cu EXTRUSION OF TSV AND ITS SUPPRESSION FOR THREE-DIMENSIONAL PACKAGING</b> <u>S. H. Kee, M. H. Roh, S. J. Lee, J. P. Jung, W. J. Kim</u> <i>Dept. of Materials Science and Engineering, University of Seoul, Korea</i>	<b>R9</b>
18:00-19:00	<b>BREAK</b>	
19:00	<b>DINNER &amp; SOCIAL EVENT (TORCH-LIT WALK)</b>	

	<b>TUESDAY, DECEMBER 9th, 2014</b>	<b>PART NO.</b>
Session	<b>ORAL SESSION V (PLENARY)</b>	
Room	<b>SEEBLICK</b>	
Chair	<b>M. Mayer, P. Gröning</b>	
08:20	<b>FEMTOSECOND LASER NANOSTRUCTURING, PRINTING OF NANOPARTICLES, AND MICRO-JOINING</b> <u>B. Chichkov</u> <i>Laser Zentrum Hannover e.V., Germany</i>	<b>KEYNOTE</b>  <b>K4</b>
09:00	<b>FORMATION AND CHARACTERIZATION OF SUBCLUSTER SEGREGATED NANOALLOY WITH FEMTOSECOND LASER IRRADIATION</b> <b>Z.Jiao<sup>1,2</sup>, W. Duley<sup>3</sup>, N. Zhou<sup>2,4</sup>, P. He<sup>1</sup></b> <sup>1</sup> <i>State Key Laboratory of Advanced Welding Production Technology, Harbin Institute of Technology, Harbin 150001, China</i> <sup>2</sup> <i>Centre for Advanced Materials Joining, University of Waterloo, Canada</i> <sup>3</sup> <i>Dept. of Physics &amp; Astronomy, University of Waterloo, Canada</i> <sup>4</sup> <i>Dept. of Mechanical and Mechatronics Engineering, University of Waterloo, Canada</i>	<b>INVITED</b>  <b>I8</b>
09:20	<b>ULTRA-LOW POWER INTEGRATED PH NANOSENSORS</b> <b>A. M. Ionescu, S. Rigante, E. Buitrago</b> <i>Nanolab, Ecole Polytechnique Fédérale de Lausanne, Switzerland</i>	<b>INVITED</b>  <b>I9</b>
09:40	<b>GROWTH AND ASSEMBLY OF GRAPHENE THIN FILMS ON INSULATING SUBSTRATES</b> <b>T. Ogino</b> <i>Division of Electrical and Computer Engineering, Yokohama National University, Japan</i>	<b>INVITED</b>  <b>I10</b>
10:00-10:30	<b>COFFEE BREAK</b>	
Session	<b>ORAL SESSION VI (PLENARY)</b>	
Room	<b>SEEBLICK</b>	
Chair	<b>F. Baras, H. Nishikawa</b>	
10:30	<b>JOINING REFRACTORY AND DISSIMILAR MATERIALS USING REACTIVE NANOFOILS</b> <b>A.S. Rogachev<sup>1,2</sup>, A.S. Mukasyan<sup>2,3</sup>, S.G. Vadchenko<sup>1</sup>, A.A. Nepapushev<sup>2</sup></b> <sup>1</sup> <i>Inst. of Structural Macrokinetics &amp; Material Science Russian Academy of Science (ISMAN), Russia</i> <sup>2</sup> <i>Center of Functional Nano-Ceramics, National University of Science and Techn., "MISIS", Russia</i> <sup>3</sup> <i>Dept. of Chemical and Biomolecular Engineering, University of Notre Dame, USA</i>	<b>INVITED</b>  <b>I11</b>
10:50	<b>ADVANCED NANOSTRUCTURE FORMATION VIA INTERFACE AND GRAIN BOUNDARY TAILORING</b> <b>S. Baylan<sup>1</sup>, G. Richter<sup>1</sup>, M. Beregovsky<sup>2</sup>, D. Amram<sup>2</sup>, E. Rabkin<sup>2</sup></b> <sup>1</sup> <i>Max Planck Institute for Intelligent Systems, Germany</i> <sup>2</sup> <i>Dept. of Materials Science and Engineering, Technion, Israel</i>	<b>INVITED</b>  <b>I12</b>
11:10	<b>NANOJOINING: FROM NANOSINTERING TO 3D NANOMANUFACTURING</b> <b>A. Hu<sup>1</sup>, R. Li<sup>1,2</sup>, Q. Ma<sup>1</sup>, D. Bridges<sup>1</sup></b> <sup>1</sup> <i>Dept. of Mechanical, Aerospace and Biomedical Eng., University of Tennessee Knoxville, USA</i> <sup>2</sup> <i>Dept. of Electrical Engineering, Southeast University, China</i>	<b>INVITED</b>  <b>I13</b>
11:30	<b>PATTERNING OF INDIUM TIN OXIDE MICROWIRES USING LASER-INDUCED THERMAL PRINTING METHOD</b> <b>T. Sano<sup>1</sup>, S. Iwasaki<sup>1</sup>, S. Katsura<sup>2</sup>, K. Yoshida<sup>3</sup>, A. Nakayama<sup>4</sup>, A. Hirose<sup>1</sup></b> <sup>1</sup> <i>Div. of Materials and Manufacturing Science, Graduate School of Eng., Osaka University, Japan</i> <sup>2</sup> <i>Nippon Denki Kagaku Co., Japan</i> <sup>3</sup> <i>General Co., Ltd., Japan</i> <sup>4</sup> <i>Ion Technology Center Co., Ltd., Japan</i>	<b>INVITED</b>  <b>I14</b>
11:50	<b>EX- AND IN-SITU X-RAY BASED ANALYTICAL STUDIES ON SOLDER MATERIALS FOR MICROSYSTEMS PACKAGING APPLICATIONS</b> <b>A. Neels<sup>1</sup>, T. Bandí<sup>2</sup>, R. Kaufmann<sup>1</sup>, J. Janczak-Rusch<sup>1</sup>, L.P.H. Jeurgens<sup>1</sup>, A. Dommann<sup>1</sup></b> <sup>1</sup> <i>Empa, Swiss Federal Laboratories for Materials Science and Technology, Switzerland</i> <sup>2</sup> <i>SSC, Ecole Polytechnique Fédérale de Lausanne (EPFL), Switzerland</i>	<b>R10</b>
12:10-13:30	<b>LUNCH</b>	

	TUESDAY, DECEMBER 9th, 2014	PART NO.
Session	ORAL SESSION VII (PARALLEL)	
Room	WALDHORN (ROOM 1)	
Chair	L. Quintino, J-P. Jung	
13:30	<b>SOLID-LIQUID DIFFUSION BONDING OF COPPER USING Sn/Ag MULTILAYERED FILMS</b> <b>S. Fukumoto<sup>1</sup>, K. Miyake<sup>2</sup>, M. Matsushima<sup>1</sup>, K. Fujimoto<sup>1</sup></b> <sup>1</sup> Graduate School of Engineering, Osaka University, JAPAN <sup>2</sup> Graduate Student of Osaka University, JAPAN	R12
13:50	<b>NANO-SIZE Ag/AlN MULTILAYERS FOR LOW TEMPERATURE JOINING APPLICATIONS</b> <b>M. Chiodi, F. Moszner, C. Cancellieri, G. Pigozzi, J. Janczak-Rusch, L.P.H. Jeurgens</b> <i>Empa, Swiss Federal Laboratories for Materials Science and Technology, Switzerland</i>	R14
14:10	<b>AQUEOUS Cu NANOPARTICLE INK STABILIZED BY PVP-SDS</b> <b>A. Y. Li<sup>1,2</sup>, B. H. Wang<sup>2</sup>, C. Yao Huo<sup>2</sup></b> <sup>1</sup> State Key Laboratory of Advanced Welding & Joining, School of Materials Science & Engineering Harbin Institute of Technology, China <sup>2</sup> School of Materials Science and Engineering, Harbin Institute of Technology at Weihai, China	R16
14:30	<b>MELTING, MIXING AND NUCLEATION AT INTERFACES IN Ni-AI NANOFOILS : A MOLECULAR DYNAMICS APPROACH</b> <b>V. Turlo, O. Politano, F. Baras</b> <i>Laboratoire ICB, UMR 6303 CNRS-Université de Bourgogne, FRANCE</i>	R18
14:50	<b>START TEMPERATURE MANIPULATION AND EFFICIENCY IMPROVING OF SELF-PROPAGATION CHEMICAL REACTIONS IN MULTILAYERED THERMITE MATERIALS BASED ON ALUMINUM-COPPER NITRIDE COMPOSITE</b> <b>D. G. Gromov<sup>1</sup>, E. A. Lebedev<sup>1</sup>, S. P. Timoshenkov<sup>1</sup>, Yu. I. Shilyaeva<sup>1</sup>, V. A. Galperin<sup>2</sup>, D. I. Smirnov<sup>3</sup>, E. P. Kirilenko<sup>4</sup></b> <sup>1</sup> National Research University of Electronic Technology, Russia <sup>2</sup> Science Manufacturing complex "Technological Center", Russia <sup>3</sup> Lebedev Physical Institute of Russian Academy of Science, Russia <sup>4</sup> Science-Technological center "Nano- and Microsystems technics", Russia	R20
15:10	<b>INVESTIGATION OF COPPER-BASED NANOSTRUCTURED MULTILAYER SYSTEMS FOR BRAZING APPLICATIONS</b> <b>W. Tillmann, B. Lehmert, L. Wojarski, M. Kuck</b> <i>TU Dortmund, Institute of Materials Engineering, Germany</i>	R22
15:30-16:00	Coffee Break	
Session	ORAL SESSION VIII (PARALLEL)	
Room	WALDHORN (ROOM 1)	
Chairperson	P. He, M. Yavuz	
16:00	<b>FEMTOSECOND LASER INDUCED NANOJOINING</b> <b>L. Liu<sup>1,2</sup>, L. Lin<sup>1</sup>, D. Shen<sup>1</sup>, H. Bai<sup>1</sup>, G. Zou<sup>1</sup>, Y.N. Zhou<sup>3</sup></b> <sup>1</sup> Dept. of Mechanical Engineering, Tsinghua University, China <sup>2</sup> The State Key Laboratory of Tribology, Tsinghua University, China <sup>3</sup> Dept. of Mechanical & Mechatronics Engineering, University of Waterloo, Canada	R24
16:20	<b>TRANSIENT THERMAL IMPEDANCE OF IGBT MODULES JOINED BY LEAD-FREE SOLDER AND SINTERED NANOSILVER</b> <b>M.Y. Wang<sup>1</sup>, Y.H. Mei<sup>1</sup>, X. Li<sup>1</sup>, G.Q. Lu<sup>1,2</sup></b> <sup>1</sup> Tianjin Key Laboratory of Advanced Joining Technology, School of Material Science and Engineering, Tianjin University, China <sup>2</sup> Dept. of Material Science and Engineering, Virginia Tech, USA	R26
16:40	<b>LASER ASSISTED LOW TEMPERATURE HERMETIC SEALING OF OPTOELECTRONICS DEVICES</b> <b>R. Jose James<sup>1</sup>, E. Rutz<sup>1</sup>, T. Stadelmann<sup>1</sup>, S. Berchtold<sup>1</sup>, M. Lützelshwab<sup>1</sup>, Ch. Bosshard<sup>1</sup>, M. Epitau<sup>2</sup>, A. Hold<sup>2</sup>, C. Vélez<sup>2</sup></b> <sup>1</sup> CSEM SA, Switzerland <sup>2</sup> Exalos AG, Switzerland	R28
17:00	<b>EFFECTS OF HEAT TREATMENT ON RESISTANCE MICROWELDING JOINTS OF CROSSED NITINOL WIRES</b> <b>Y. Huang<sup>1,2</sup>, A. Pequegnat<sup>2</sup>, N. Zhou<sup>2</sup></b> <sup>1</sup> National Defense Key Disciplines Laboratory of Light Alloy Processing Science and Technology, Nanchang Hangkong University, China <sup>2</sup> Centre for Advanced Materials Joining, University of Waterloo, Canada	R30
17:20	Transfer to Poster Session SEEBLICKSAAL	
17:30	POSTER SESSION SEEBLICK	
19:00	Break	
20:00	SWISS GALA DINNER	

	TUESDAY, DECEMBER 9th, 2014	PART NO.
Session	ORAL SESSION IX (PARALLEL)	
Room	ZEDER (ROOM 2)	
Chairperson	T. Ogura, G. Grossmann	
13:30	<b>IMPROVEMENT OF IMPACT RELIABILITY OF SOLDER BUMPS USING LASER PROCESS</b> <b>H. Nishikawa<sup>1</sup>, N. Iwata<sup>2</sup></b> <sup>1</sup> Joining and Welding Research Institute, Osaka University, Japan <sup>2</sup> Graduate School of Engineering, Osaka University, Japan	R13
13:50	<b>DISPLACEMENT ANALYSIS OF BONDING WIRES UNDER DC CURRENT</b> <b>T. Dagdelen<sup>1</sup>, M. Khater<sup>2</sup>, S. Park<sup>2</sup>, R. Saritas<sup>1</sup>, E. Abdel-Rahman<sup>2</sup>, M. Yavuz<sup>1</sup></b> <sup>1</sup> Mechanical and Mechatronics Engineering Department, University of Waterloo, Canada <sup>2</sup> Department of System Design Engineering, University of Waterloo, Canada	R15
14:10	<b>INTERMETALLIC COMPOUND JOINTS PRODUCED BY ULTRASONIC SOLDERING PROCESS IN Cu/Sn/Cu SYSTEM</b> <b>M. Li<sup>1,2</sup>, Z. Li<sup>1</sup>, C. Wang<sup>2</sup></b> <sup>1</sup> Shenzhen Key Laboratory of Advanced Materials, Harbin Institute of Technology Shenzhen Graduate School, HIT Campus, The University Town of Shenzhen, China <sup>2</sup> State Key Laboratory of Advanced Welding and Joining, Harbin Institute of Technology, China	R17
14:30	<b>MECHANICAL RESPONSE ON Cu-Sn INTERMETALLICS</b> <b>F. Wang, X. Li, and K. Qi</b> Provincial Key Laboratory of Advanced Welding Technology, Jiangsu University of Science and Technology, China	R19
14:50	<b>SHEAR STRENGTH DEGRADATION OF Pb-FREE SOLDER JOINT WITH MOUNTED LOCATION IN AUTOMOBILE</b> <b>W. S. Hong, A Young Kim</b> Components & Materials Physics Research Center, Korea Electronics Technology Institute	R21
15:10	<b>3D STEREO LITHOGRAPHIC PRINTING OF TERAHERTZ WAVE PHOTONIC CRYSTALS THROUGH MICRO JOINING OF OXIDE AND METALLIC GLASSES</b> <b>S. Kirihara</b> Joining and Welding Research Institute, Osaka University, Japan	R23
15:30-16:00	Coffee Break	
Session	ORAL SESSION X (PARALLEL)	
Room	ZEEDER (ROOM 2)	
Chairperson	D.G. Gromov, T. Sano	
16:00	<b>INSPECTION OF MICRO DEFECTS USING BACTERIAL CELLS</b> <b>T. G. Santos<sup>1</sup>, R.M. Miranda<sup>1</sup>, L. Quintino<sup>2</sup>, C.C.C.R. de Carvalho<sup>3</sup></b> <sup>1</sup> UNIDEMI, Departamento de Engenharia de Medicina e Industrial, Faculdade de Ciências e Tecnologia, Universidade Nova de Lisboa, Portugal <sup>2</sup> IDMEC, Instituto Superior Técnico, Universidade de Lisboa, Portugal <sup>3</sup> Institute of Biotechnology and Bioengineering, Centre for Biological and Chemical Engineering, Dept. of Bioengineering, Instituto Superior Técnico, Universidade de Lisboa, Portugal	R25
16:20	<b>STABILITY AND MELTING OF FCC TRUNCATED OCTAHEDRAL AG NANOPARTICLES BY MOLECULAR DYNAMICS SIMULATION</b> <b>H. Alarifi<sup>1</sup>, M. Atiş<sup>2</sup>, C. Özdoğan<sup>3</sup>, A. Hu<sup>4</sup>, M. Yavuz<sup>5</sup>, Y. Zhou<sup>5</sup></b> <sup>1</sup> King Abdulaziz City for Science and Technology, Saudi Arabia <sup>2</sup> Kayseri Vocational School, Department of Electricity and Energy, Erciyes University, Turkey <sup>3</sup> Dept. Materials Science and Engineering, Cankaya University, Turkey <sup>4</sup> Dept. Mechanical, Aerospace and Biomedical Eng., University of Tennessee Knoxville, USA <sup>5</sup> Dept. Mech. & Mechatronics Eng., Centre for Adv. Mater. Joining, Univ. of Waterloo, Canada	R27
16:40	<b>NUMERICAL ANALYSIS OF MICROBUBBLE BEHAVIOR AND MICROPOROSITY FORMATION IN LASER BEAM WELDS OF ALUMINIUM ALLOY</b> <b>H. Mori<sup>1</sup>, Q. Zhou<sup>1</sup>, K. Koyama<sup>1</sup>, F. Miyasaka<sup>2</sup>, Y. Murakami<sup>3</sup>, Y. Kawahito<sup>3</sup>, M. Mizutani<sup>3</sup>, S. Katayama<sup>3</sup></b> <sup>1</sup> Osaka University, Graduate School of Eng., Dept. of Management of Industry & Techn., Japan <sup>2</sup> Osaka University, Department of Adaptive Machine Systems, Japan <sup>3</sup> Osaka University, Joining and Welding Research Institute, Japan	R29
17:00	<b>EFFECT OF ITO INTERLAYER ON THE Au/Hg<sub>3</sub>In<sub>2</sub>Te<sub>6</sub> SCHOTTKY CONTACT CHARACTERISTICS</b> <b>L. Yapeng, C. Liu, L. Fu</b> State Key Laboratory of Solidification Processing, School of Materials Science and Engineering, Northwestern Polytechnical University, China	R31
17:20	Transfer to Poster Session SEEBLICKSAAL	
17:30	POSTER SESSION SEEBLICK	
19:00	Break	
20:00	SWISS GALA DINNER	



	TUESDAY, DECEMBER 9th, 2014	PART NO.
Session	<b>POSTER SESSION</b>	
Room	<b>SEEBLICK</b>	
18:00	<p><b>LOW-TEMPERATURE COMBUSTION JOINING OF CARBON/CARBON COMPOSITES</b>  <u>A.A. Nepapushev</u><sup>1</sup>, Ya-Cheng Lin<sup>2</sup>, A.S. Rogachev<sup>1,3</sup>, P.J. McGinn<sup>2</sup>, A.S. Mukasyan<sup>1,2</sup>,  <sup>1</sup>National University of Science and Technology, Russia  <sup>2</sup>Dept. Chem. &amp; Biomolec. Eng., University of Notre Dame, USA  <sup>3</sup>Institute of Structural Macrokinetics &amp; Materials Science Russian Academy of Sciences, Russia</p>	<b>P1</b>
	<p><b>THE MECHANISM OF MELTING POINT DEPRESSION AISi/AIN IN NANOMULTILAYERED SYSTEMS</b>  <u>J. Lipecka</u><sup>1</sup>, M. Andrzejczuk<sup>1</sup>, M. Lewandowska<sup>1</sup>, G. Richter<sup>3</sup>, J. Janczak-Rusch<sup>1,2</sup>, L.P.H. Jeurgens<sup>2</sup>  <sup>1</sup>Warsaw University of Technology, Poland  <sup>2</sup>Empa, Swiss Federal Laboratories for Materials Science and Technology, Switzerland  <sup>3</sup>Max Planck Institute for Intelligent Systems, Germany</p>	<b>P2</b>
	<p><b>EFFECTS OF WARPAGE ON HIP DURING BGA PACKAGING</b>  <u>Z. Zhao</u><sup>1</sup>, Ch. Chen<sup>2</sup>, Y. Wang<sup>3</sup>, Ch.Y. Park<sup>4</sup>, L. Liu<sup>1</sup>, J. Cai<sup>2</sup>, Q. Wang<sup>2</sup>, H. Bai<sup>1</sup>, G. Zou<sup>1</sup>  <sup>1</sup>Dept. of Mechanical Engineering, Tsinghua University, China  <sup>2</sup>Institute of Microelectronics, Tsinghua University, China  <sup>3</sup>Training Center for Basic Industry, Tsinghua University, China  <sup>4</sup>Samsung Electronics Co. Ltd, Korea</p>	<b>P3</b>
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